Deposition and Tribology of Carbon and Boron Nitride Nanoperiod Multilayer Hard and Solid Lubricating Films

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1. Introduction

In the tribology application of thin films, in order to improve wear resistance properties, super hard films composed of boron, carbon and nitrogen have attracted much attention in recent years as known boron, carbon and nitrogen are used as basic component elements (Enomoto, Miyake, 1994; Miyake, 1999; Miyake et al., 1994). As also, it is expected to realize the application of solid lubricant films which will be provided super low friction coefficients to improve the lubricant properties of surfaces.

More and more so-called solid lubricant films in stead of lubricant oil are expected to work under such extreme conditions as high-temperature and vacuum operations in which lubricant oil is unqualified to run. In these solid lubricant materials, the representatives are soft metals as Au and Ag, crystallizing layered inorganic compounds as graphite, h-BN, MoS₂ (molybdenum disulfide) and WS₂ (tungsten disulfide) and polymers as PTFE (polytetrafluoroethylene) et al. (Enomoto & Miyake, 1994). On the other hand, a wear-resistant, not the conventional solid lubricant film, is desired to reduce atomic-scale wear and friction force fluctuation (Miyake et al., 1994; Miyake, 1994; Miyake et al., 1992). One candidate is carbonaceous films such as diamond and diamond like carbon films, which have wear-resistant and lubricating properties (Miyake et al., 1994; Miyake, 1994; Miyake & Kaneko, 1992).

The volume module of a hypothetical material, β -C₃N₄, which is structurally analogous to β -C₃N₄, may be larger than or equal to that of diamond (Liu & Cohen, 1989). The hardness of this stoichiometric crystalline carbon nitride is expected to exceed that of diamond. Partially crystalline carbon nitride films have been deposited by reactive sputtering, and their structure and compositions have been investigated. In our previous studies, the use of an atomic force microscope enabled accurate evaluation of the effect of nitrogen inclusions on nanoindentation hardness and microwear (Miyake et al., 1994).

Research on the development of nanoperiod multilayer films has recently been carried out, to improve the film hardness. For example, hard multilayer films were deposited, and it was found that the hardness of these multilayer films was significantly improved compared with that of one monolayer of them. As a super hard film, the superlattice film laminated with

thin layers by several nanometers was investigated. Concretely, superlattice films such as CN_x/TiN (Li et al., 1995) and TiN/AlN (Nakayama, 1997) were performed. In our studies, the (CN/BN)_n multilayer film was proposed to deposit using boron nitride and carbon nitride layer by layer (Miyake et al., 1999) to form a novel superlattice film and its properties were investigated. The hardness enhancement mechanism of a superlattice film is based on the restriction of dislocation movement within and between layers in the superlattice film (Donohue et al., 1995). In our previous study, a nanoperiod (CN/BN)_n multilayer film was deposited in order to improve its hardness (Miyake & Sekine, 2000). The nanoindentation hardness and modulus of dissipation of a 4-nm-period multilayer film are the highest and the lowest among other multilayer films (Miyake, 2003). The dependence of atomic-order wear properties on sliding cycles indicates that the wear resistance increased at the interface between the CN and BN layers of the multilayer films (Miyake, 2003).

Generally, friction force is proportional to contact area A and shearing strength S , i.e. $F = AS$. Friction coefficient μ is defined as friction force F divided by load W , i.e. $\mu = F/W = AS/W$. Hardness is defined as $H = W/A$. Therefore, $\mu = S/H$, i.e. the friction coefficient μ is approximately proportional to the ratio of shearing strength S to hardness H (Bowden et al., 2004). To develop new low-friction solid lubricant films, the hardness H must be increased and the shearing strength S must be decreased, as shown in Fig. 1 (Miyake et al., 2004). Therefore, nanoperiod multilayer films composed of low-shearing-strength graphite and hexagonal boron nitride (h-BN) that have solid lubricating properties, are expected to have a low friction coefficient because the hardness is increased due to the nanoperiod multilayered structure, while the shearing strength is decreased due to the inclusion of the low-shearing-strength C and BN layers (Miyake et al., 2004).

Fig. 1. Low-friction model of nanoperiod multilayer solid film: as the shearing strength S is constant, μ decreases with an increase in hardness.

In this study, by utilizing the superlattice film technique above, the hard films were proposed to deposit and their hardness in perpendicular direction were significantly increased with increasing their elastic moduli. It is considered that the friction coefficient is decreased due to the effect of the hardness increases as keeping the shear resistance of a sliding plane paralleling its substrate. Our aim is focused on developing a new solid lubricant film with an extremely low friction which usual simple film and mixed film

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multilayer, BN and C films. Micro-Vickers hardness was measured at a load of 0.05 N and the load duration of 10 s. Nanoindentation test were performed at a maximum load of 100 μN . The hardness was geometrically calculated from the Ar section area of plastic deformation using the plastic deformation depth and P_{max} maximum load. Plastic deformation depth was determined from the point of intersection of the straight line fitted to the appropriate unloading curve and the x axis to the point of the maximum deformation depth on x axis. The hardness H is evaluated from Eq. (1)

$$H = P_{\text{max}} / A_r \quad (1)$$

The nanoindentation hardness and surface deformation properties of the films were investigated using AFM (Digital instruments Nanoscope III) together with a nanoindentation measurement system (Hysitron Inc.). The nanoindentation hardness was measured by AFM with a Bercovich-type diamond indenter (a three-sided pyramid diamond tip) with a radius of about 100 nm, under 20~25 °C temperature and 30~50 % humidity conditions. The diamond tip is regularly checked using a quartz standard item. These films were as thin as 200 nm, therefore, the nanoindentation hardness value evaluated under higher load was influenced by the substrate hardness. As a result, the hardness value of these films evaluated by this method under higher load is lower than that of real film. The test was performed with a loading time of 20 s at 60-100 μN load. Here, the hardness is evaluated from the plastic deformation depth. The plastic deformation depth was evaluated from the intersection point of the y-axis and the straight line fitting from the appropriate unloading curve (Doerner & Nix, 1986). In this study, the Vickers and nanoindentation hardness values of the silicon substrate were 1500 and 13 GPa, respectively.

To evaluate the deformation behavior using the nanoindentation test, energy analysis of the nanoindentation curve was performed. Total deformation energy was calculated using the integral of the loading curve as shown in Fig. 3. The storage energy was calculated using the integral of the unloading curve. The dissipated energy was evaluated from the remainder of the total energy minus the storage energy. The modulus of dissipation was calculated by dividing the dissipated energy by the total energy (Donohue et al., 1995; Miyake et al., 2004; Miyake, 2005).

The hardness was evaluated from the plastic deformation depth which was determined from the point of intersection of the straight line fitted to the appropriate unloading curve and the x axis (Doerner & Nix, 1986; Syed Asif et al., 1999; Miyake & Kim, 2003). The total deformation energy of nanoindentation was calculated as the integral of the loading curve. Storage energy was calculated as the integral of the unloading curve. As shown in Fig. 3, dissipated energy was evaluated as the total energy minus storage energy.

To clarify the tribological characteristic of an extremely thin film, an AFM with a diamond tip with a radius of about 50 nm was employed to observe the surface profile and microwear properties. A schematic representation of the evaluation is shown in Fig. 4. The oscillation scratch tests were performed with gradually increasing loads using the diamond tip indenter under setting conditions of a 6.7 $\mu\text{N/s}$ loading speed, a 200 μN maximum load. In addition, the oscillation scratch test was carried out to evaluate the fracture characteristics and adhesion strength of the film by measuring an acoustic emission (AE) signal which can indicate a critical load in the test.

Wear-resistance of the films was determined with a ball-on-disk tribometer opening under RT ~400 °C. As shown in Fig. 5, a disk specimen deposited a multilayer film was tested.

The opposing stainless-steel ball (radius of 3.2 mm) was slid against the specimen being set rotating. Friction force was measured by the strain gauge attached to the plane spring mounted the tribometer. Data on the friction coefficient were obtained without lubricant and a normal load of 9.8 N, a sliding speed of 94 mm/s and a room temperature of 25, 200 and 400 °C, and a relative humidity of approximately 40~60 %. After the friction test, the wear tracks of the sample were observed by AFM and using an optical microscope and three-dimensional profile meter. The friction test was performed more than three times, and the mean and typical data were discussed. The variation of saturated friction value is less than 15 %.

Fig. 3. Evaluation method of nanoindentation test

Fig. 4. Schematic representation of a load gradual increase nanoscratching test

Fig. 5. High-temperature tribometer

3. Results and discussion

3.1 Composition and structure of deposited films

The total thicknesses of all the films tested were set at nearly 200 nm. A crystalline structure cannot be detected by X-ray diffraction analysis, FTIR and TEM. These single-layer and multilayer films are found to be amorphous from these microanalyses (Miyake, 2005). From the Raman spectrum, the differences between these carbon-containing films were not clearly evaluated (Miyake, 2005).

In a previous paper, a transmission-electron microscopy (TEM) image of a nano-meter-period multilayered film composed of alternate C-N and B-N layers was obtained and the structure of the period-layered CN/BN was clarified. The thicknesses of both the C-N and B-C-N layers were controlled so as to be nearly identical. The period of this TEM image of the multilayer film is 8 nm, therefore the thickness of each C-N and B-N layer is about 4 nm. Even though the layers are very thin, each layer can be distinguished (Miyake, 2003). Moreover, atomic concentrations of boron, carbon and nitrogen elements classified as super-hard film materials were detected according to Auger electron spectroscopy (AES) measurement of the depth profile of the multilayered films (Miyake et al., 2000). The C/BN multilayers discussed in this study were deposited by the same deposition method as that mentioned above. By controlling deposition time and using different targets, the (C/BN) n films were deposited as expected.

3.2 Micro Vickers hardness and nanoindentation hardness

The results of micro Vickers hardness of these thin films are shown in Fig. 6. The precise measurement could not be carried out for the BN simple layer film because there was some frictional peeling on the substrate after the test. Exactly as a expected effect of solid lubricant films, the micro Vickers hardness of (C/BN) n multilayer films synthesized in our study is changed with changing the multilayer period of the films. The hardness of the 4 nm (C/BN) n multilayer film shows the highest in all (C/BN) n films.

The nanoindentation curves show a relationship between indenter penetration depth and load of these films obtained at 100 μm as shown in Fig. 7. Therefore, the nanoindentation hardness can be evaluated from the nanoindentation curves and the results are shown in Fig.

8. In the case of the BN film, as the indentation depth caused by an indenter was drastically fluctuated in the nanoindentation test, the result of the BN film in this test can not be reproducible. According to the indentation curves of the films, the maximum indentation depths of C simple film, 2- and 8-nm-period (C/BN)_n films are quite similar and close to 15 nm, and it can be confirmed that the plastic deformation depth is nearly 3 nm. Upon the curves, it is observed that the deformation depth of the 4-nm-period (C/BN)_n film shows a tendency to decrease significantly. The curve of indentation depth of the 4-nm-period (C/BN)_n film is near that of the 4-nm-period (CN/BN)_n film and shows the same tendency to decrease on its indentation depth. It is to say that elastic deformation mainly occurred on the surface of these multilayer films in the indentation test and the films exhibit excellent hardness. In particularly, the indentation hardness of the 4-nm-period (C/BN)_n film is highest in all (C/BN)_n films.

Fig. 6. Vickers hardness of super lattice films

When measuring the films in the micro Vickers test, the hardness could not be really measured by an indenter because the indenter would destroy those films and pierce through them, then reached the substrate of Si wafer. Hence, it was considered that the hardness of the film can not be exactly measured due to the influence of the substrate. In contrast, the hardness measurement will be hardly affected by the substrate employed as the groundwork in the nanoindentation test, because the indentation depth of the indenter is only about 3 to 17 nm. Therefore, the hardness of these films could be really investigated and measured by the nanoindentation test. Upon the indentation test, it is obvious that the (C/BN)_n multilayer film with a layer period of nearly 4 nm show the highest hardness.

Furthermore, the indentation hardness of C and BN monolayer and (C/BN)_n multilayer films was evaluated and compared at maximum applied loads of 60, 80, and 100 μ N. Compared with the elastic-plastic properties of the (C/BN)_n multilayer films, the maximum indentation depth ($h_{\max}$) of the 4-nm-period multilayer film is less than that of the other films. The estimated average indentation hardness values in this study are summarized in Fig. 9. The hardness of all multilayer films is higher than that of the C and BN single layer films. It is observed that the nanoindentation hardness of the multilayer film changes with a change in a layer period. The multilayer film with the 4-nm-period film shows the highest hardness among all multilayer films in the study, indicating that the tribological properties

of the multilayers, such as low friction coefficient and high wear-resistance, i.e. long wear life, were improved compared with those of the single layer (Miyake, 2005). Corresponding to this, the 4-nm-period film shows the highest hardness.

Fig. 7. Nanoindentation curves of 4-nm-period (CN/BN)_n, 2-, 4- and 8-nm-period (C/BN)_n super lattice films

Fig. 8. Nanoindentation hardness of C film and (CN/BN)_n and (C/BN)_n super lattice films

The relationship between the modulus of dissipation, nanoindentation hardness (H) and the material factor of index of plasticity (E/H) for the monolayer and multilayer films is shown in Fig. 10. E/H is a quantity value which is used to express the plastic deformation of material in the plastic index of material constant (Taniguchi, 1996). The modulus of dissipation and the E/H decrease with an increase in nanoindentation hardness. The dissipated and storage energies of these films were evaluated. Compared with the single

layer films, the total energy of the nanoperiod multilayer films decreased, and in particular, the dissipated energy of the multilayer films significantly decreased. Figure 10 shows the modulus of dissipation, which is calculated from the ratio of dissipated energy to total energy of the indentation. It is evident that the modulus of dissipation of the multilayer films was reduced to less than 50 % due to the nanoperiod multilayer structure.

As shown in Fig. 10, the modulus of dissipation decreases with increasing hardness. It is considered that the deformation of multilayer films is mainly elastic deformation, along

Fig. 9. Nanoindentation hardness as a function of layer-periods for single layer and multilayer films (error bars: 3σ)

Fig. 10. Modulus of dissipation and the material factor of index of plasticity (E/H) as a function of nanoindentation hardness for single layer and multilayer films

with a low dissipation energy. The material factor of index of plasticity (E/H) was evaluated as Young's modulus E divided by hardness H (Miyake et al., 2004). The nanoindentation hardness is defined as the resistance to plastic deformation per unit area. On the other hand, the modulus of dissipation and E/H corresponds to the ease of plastic deformation. By indentation testing, the hardest 4-nm-period multilayer film shows the lowest modulus of dissipation and E/H , i.e. it has less dissipated permanent deformation due to indentation. This is considered that the nucleation and propagation of the lateral cracks beneath the indentation were limited due to the nanostructure of the multilayer (Bhushan, 1995). Therefore, the relationship among nanoindentation hardness, the modulus of dissipation and E/H was expressed approximately as a simple empirical formula for investigation and analysis of the nanoscale mechanical properties of film.

3.3 Tribological properties

The measured results of the frictional force and friction coefficient in the nano scratch test are shown in Fig.11. Upon the results, the frictional force of the BN film varies drastically and shows the highest value at the loads of 0 to 20 μN . It can be considered that the hardness of the BN film is lower than those of other films, therefore, the destruction on its surface easily occurred even from the beginning of the test and the frictional force of its surface shows to increase sharply. On the other hand, upon investigating the friction dependence of the $(\text{C}/\text{BN})_n$ multilayer films on the period, it could be confirmed that the effect of the reduction in the frictional force of the $(\text{C}/\text{BN})_n$ multilayer film with the period of 4 nm is significantly remarkable, and its hardness similarly exhibits a maximum value. With respect to the friction coefficients of these films, the initial values of the friction coefficients display drastically fluctuated, but they become steady with a load being over 40 μN . Upon the results, the friction coefficient of BN simple layer film is as high as $\mu = 0.45$ from 40 μN load and those of 2- and 8-nm-period $(\text{C}/\text{BN})_n$ films are $\mu = 0.28$ and $\mu = 0.24$, respectively. The friction coefficients of the carbon film and 4-nm period $(\text{C}/\text{BN})_n$ film are as low as $\mu = 0.22$ and $\mu = 0.17$, respectively. It could be found that the friction coefficients of films would show a tendency to decrease with the hardness increasing. As the hardness of the 4-nm-period $(\text{C}/\text{BN})_n$ film is increased at the lamination direction and the shear strength of its scratch plane is nearly similar to that of the simple layer film which has the characteristic value, it can be consider that the friction coefficient μ of the $(\text{C}/\text{BN})_n$ film is able to decrease due to its hardness increase according to the Eq. (2) when its shear strength is almost the same as that of the simple layer film. The equation shows as follows,

$$\mu = S / H \quad (2)$$

Here, S is a shear resistance and constant and H is hardness.

Figure 12 shows the section profiles of the scratch scars of all deposited films after the nanoscratch test. The maximum wear depths of the films are shown in Fig. 13. The wear scar of the 4-nm-period $(\text{C}/\text{BN})_n$ film is the smallest. In the nanoscratch test, the destruction of the simple layer film continuously becomes degraded with gradually increasing the test load, whereas that of the superlattice film can be significantly deterred due to the restraint effect of boundary plane of the multilayer film.

Moreover, it is obvious that the maximum wear depth of the film also depends on the layer period and the wear depth of the 4-nm-period $(\text{C}/\text{BN})_n$ film is reduced to a minimum. These results are corresponding to those of the nanoindentation hardness. Therefore, it is

confirmed that the wear depth of the 4-nm-period (C/BN)_n film decreases because its elastic modulus increases at the lamination direction.

The results of oscillating scratch test are shown in Fig. 14. The AE (acoustic emission) numbers could be obtained in this scratch test and the inclination of the scratch force curve is corresponding to the friction coefficient. As observing the curves, the inclination of the 4-nm-period (C/BN)_n film shows comparatively low, that is to say, the 4-nm-period (C/BN)_n film has a low friction coefficient and this result is corresponding to that in the nanoscratch test and its AE also shows very small. When the load was rapidly increased, the AE of the 4-nm-period (C/BN)_n film would increase drastically and a critical load was obtained and rather high because its surface layer destruction occurred difficultly. It became clear that the critical load of the 4-nm-period (C/BN)_n film is significantly improved more than those of the simple films and other multilayer period films, and the 4-nm-period (C/BN)_n film shows the high critical load and superior adhesion property.

Fig. 11. Friction force (a) and coefficient of friction (b) of C, BN and (C/BN)_n films in a load gradual increase nanoscratching test (diamond tip, load 0~200μN, frictional rate 6.67μN/s)

Fig. 12. Wear marks on (a) C film, (b) BN film, (c) 2-nm-period (C/BN)_n, (d) 4-nm-period (C/BN)_n and (e) 8-nm-period (C/BN)_n film, obtained by a load gradual increase nanoscratching test

Fig. 13. Maximum wear depth by a load gradual increase nanoscratching test

Fig. 14. AE (Acoustic emission) and friction force as functions of indentation load for (a) C film, (b) BN film, (c) 2-nm-period (C/BN)_n, (d) 4-nm-period (C/BN)_n and (e) 8-nm-period (C/BN)_n film, obtained by scratching test

The dependence of the friction coefficient of C and BN monolayer and (C/BN)_n multilayer films on sliding cycle was investigated under a load of 9.8 N, a sliding speed of 94 mm/s and a room temperature of 25 °C, as shown in Fig. 15. The friction coefficient of the C film is $\mu = 0.3$ high at sliding cycles from 0 to 1000 and sharply increased to $\mu = 0.6$ at sliding cycles of 1000 and above. Corresponding to this, the friction coefficients of the 4- and 8-nm-period (C/BN)_n films remain comparatively low at nearly $\mu = 0.15$. Wear is hardly observed on the surface of 4- and 8-nm-period (C/BN)_n films. As the surface of these films was magnified to

observe, damage mark could be found on the 8-nm-period (C/BN) $_n$ film but not on the 4-nm-period (C/BN) $_n$ film, suggesting that the 4-nm-period (C/BN) $_n$ film has the lowest friction coefficient and superior wear resistance.

Fig. 15. Dependence of friction coefficient on the number of sliding cycles tested at 25 °C

The dependence of the friction coefficient of the nanoperiod (C/BN) $_n$ film on sliding cycles was evaluated at an environment temperature of 200°C, as shown in Fig. 16. The friction coefficients of the C and BN single-layer films are high and markedly increase with sliding cycles. However, the nanoperiod multilayer films show a low friction coefficient. In particular, the friction coefficient of the 4-nm-period multilayer film is low and stable, and it is less than 0.35 after 1800 sliding cycles.

In the tribotest performed at 400 °C temperature, it is found that at sliding cycles of less than 600, the friction coefficient of the 4-nm-period multilayer (C/BN) $_n$ is lower than that of the C, BN and other (C/BN) $_n$ multilayer films as shown in Fig. 17. Observed the surface of the films, it is found that for the C, BN and 2-nm-period films, the film was immediately removed by friction at the beginning of the test and the substrate was exposed, whereas the 4- and 8-nm-period multilayer films show a low friction coefficient. This result shows that the lubrication property of the multilayer films was improved due to its microstructure formed with an appropriate layer-period. The reason why the 4-nm-period multilayer film shows a longer life is considered to be as follows. For the single-layer films, the surface of the C or BN films was lubricated by the single layer during friction test. Since the C and BN single-layer films have a poor elastic deformation, i.e. a high modulus of dissipation, it was easily removed by friction test. Corresponding to this, since the multilayer film exhibits a low modulus of dissipation and defect elongation is prevented by the interface formed between layers (Miyake, 2003; Doerner & Nix, 1986), deep plastic deformation difficultly initiate, resulting in the wear-resistance of the film being improved. The shearing damage due to friction is suppressed due to the extremely thin layer. As a result, a longer life of the surface was obtained due to the multilayer microstructure.

Fig. 16. Dependence of friction coefficient on the number of sliding cycles tested at 200 °C

Fig. 17. Dependence of friction coefficient on the number of sliding cycles tested at 400 °C

Figure 18 shows the wear profiles of C and BN single layers and 2-, 4- and 8-nm-period multilayers after the ball-on-disk tribotest, respectively after 1000 cycles of sliding at 25 °C. In the case of the C and BN single layers, the deep wear grooves exposed the substrate surface during sliding, producing a rough wear scar and leading to a rapid increase in the friction. Corresponding to this, the wear of the 2-, 4- and 8-nm-period (C/BN) $_n$ multilayers is very small, and therefore, after 1500 cycles of sliding, the multilayered films remained on the sliding surface and still acted as a solid lubricant to prevent wear propagation. It is considered that since the multilayer film has a low modulus of dissipation, and defect elongation was prevented by the interface between layers, such as those formed in carbon nitride and boron nitride nanomultilayer films (Miyake, 2003), and therefore, deep plastic deformation is difficult to occur. The 4-nm-period film shows a better wear-resistance, this

corresponds to that it has higher hardness and lower friction coefficient compared with other films in this study.

Fig. 18. Microwear morphology of C and B single layers and (C/BN)n multilayers coated on Si substrates after 1000 cycles of sliding.

4. Conclusion

Nanoperiod multilayer films composed of carbon and boron nitride layers, which have a structure expected to provide solid lubrication, such as the h-BN and graphite structures, were respectively deposited, and their nanoindentation and frictional properties were evaluated. The following results were obtained.

1. Micro Vickers and nanoindentation hardness of the 4-nm-period multilayer film are the highest of all (C/BN)n films. The nanoindentation hardness of the nanoperiod (C/BN)n multilayer films changed with the layer period. A 4-nm-period multilayer film shows the highest hardness among all films in this study. It is considered that since the 4-nm-period multilayer has the lowest modulus of dissipation and E/H, which corresponds to the ease of plastic deformation, the 4-nm-period multilayer film has mainly elastic deformation due to indentation.
2. In nanoscratch test, the friction coefficient of 4-nm-period (C/BN)n film is the lowest. As the elastic modulus increases in the laminated direction and the change of the shear resistance of sliding plane is small in the case of 4nm-period (C/BN)n film, therefore, its friction coefficient seems to decrease.
3. The improvement effects of 4-nm-period (C/BN)n multilayer film on the decrease of the friction coefficient and damage of the wear surface were significantly remarkable and evaluated in both of the reciprocation and ball on disk type tribo tests.

4. The friction coefficient of the 4-nm-period (C/BN)_n film was the lowest, as determined by the ball-on-disk tribotest at environment temperatures of 25, 200 and 400 °C. The effect of the 4-nm-period (C/BN)_n multilayer film on improvement of friction coefficient and wear-resistance was experimentally confirmed.

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6. References

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This book aims to recapitulate old information's available and brings new information's that are with the fashion research on an atomic and nanometric scale in various fields by introducing several mathematical models to measure some parameters characterizing metals like the hydrodynamic elasticity coefficient, hardness, lubricant viscosity, viscosity coefficient, tensile strength It uses new measurement techniques very developed and nondestructive. Its principal distinctions of the other books, that it brings practical manners to model and to optimize the cutting process using various parameters and different techniques, namely, using water of high-velocity stream, tool with different form and radius, the cutting temperature effect, that can be measured with sufficient accuracy not only at a research lab and also with a theoretical forecast. This book aspire to minimize and eliminate the losses resulting from surfaces friction and wear which leads to a greater machining efficiency and to a better execution, fewer breakdowns and a significant saving. A great part is devoted to lubrication, of which the goal is to find the famous techniques using solid and liquid lubricant films applied for giving super low friction coefficients and improving the lubricant properties on surfaces.

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